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## (54) Title of the invention: AN ADJUSTABLE AUTOMATIC SHOE POLISHING DEVICE

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(31) Priority Document No	:NA	1)SHARMA, Ajay
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## (57) Abstract:

An adjustable automatic shoe polishing device is provided. The device includes a housing having a shoe inlet through which a foot with a shoe is inserted and a foot plate where the shoe is placed. A polish dispensing unit is coupled at a front end of the housing and has associated multiple knobs for dispensing polish. A brush is fixed at the front end of the shoe inlet for covering a front part of a shoe. A pair of adjustable side channels is mounted on a horizontal moving platform and is fixed along parallel adjacent walls of the housing. Each of the adjustable side channels has multiple rollers with attached brushes. An adjustable back channel is fixed at a rear end of the housing and has multiple rollers with attached brushes. The adjustable back channel is connected to the polish dispensing unit for cleaning and polishing the shoe.

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